

Alexander D. Glew, Ph.D., P.E.

Expertise (partial)

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•	Materials Science Engineering, Thin	•	Mechanical Engineering
	Films & Equipment, Semiconductor		
•	Semiconductor Equipment and	•	Licensed Professional Engineer (PE) in
	processing: CVD, Etch, RIE, CMP, SOD, EPI, MBE, RTP, and others		California, Mechanical Engineering
•	Chemical vapor deposition (CVD): plasma, ICP, thermal, MOCVD, LPCVD and others	•	CAD, drafting standards, and related.
•	Thin film processing for solar, LED, and optics.	•	Computation Fluid Dynamics (CFD) Fluid flow, radiation analysis
•	Diamond Like Carbon (DLC),	•	Finite Element Analysis (FEA), multi-
	Fluorinated amorphous carbon (FLAC)		physics and event simulation
٠	Dielectric Deposition: Low k dielectric	•	Product Design & Testing
	films, SiO2 (glass), fluorinated glass (FSG), BPSG, USG		
•	Excimer Laser Sources	•	Project management and turnaround
•	Laboratory analysis: SEM, TEM, FTIR,	•	Ultra High Purity Gas and Chemical
	SIMS, AES, and others.		Delivery Systems
•	Materials processing	•	Piping, valve, and chemical systems
•	Metal deposition and sputtering (PVD)	•	Metrology: Flow, pressure, optical properties, thin film properties
•	Plasma and Thermal Processes	•	Reverse Engineering
•	Thin Film Characterization: stress, strain, thickness, optical and dielectric properties, structure, composition	•	Safety analysis, interlocks, failure mode effects, standards and code analysis.

IP Bridge Exhibit 2008 TSMC v. Godo Kaisha IP Bridge 1 IPR2017-01841

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Employment History

From: To:	1997 Present	Glew Engineering Consulting, Inc. Mountain View, California
	Position:	President Clients include companies from semiconductor equipment, plasma generation, vacuum systems, fluid delivery systems, flow and pressure component suppliers, laser manufacturers, consumer electronics, industrial electronics, vehicle, telecommunications, and others. Consulting work includes thin film characterization, process development, project turn- around/rescue, gas flow and vacuum metrology, design of experiments, corrosive gas applications, finite element analysis and related market analysis.
From:	Aug 1987	Applied Materials, Inc.
To:	Jan 1997	Santa Clara, California
	Titles	Engineering Manager, Core-Technologist
	Project Mgr.	• Sat on corporate engineering/technology (ET) council,
	Jan 1996 to	one of 15 council members. Responsible for corporate direction
	Jan 1997	PVD RTP etch thermal and others. Also qualified gas and
		vacuum component selections Consulted with all divisions on
		gas and vacuum systems, liquid source delivery systems,
		components, and supplier selections.
		• Received patent for improved tungsten (W) CVD
		deposition.
		• Successfully proposed and executed a project that
		SEMATECH S100 funded. The goal was to develop industry
		methods to determine the effects of trace chemicals on
		semiconductor processing and equipment reliability. This
	CVD	First pph levels of impurities were introduced into both a
	Supplier	Tungsten CVD deposition process and an aluminum etching
	Quality	process. The effect on particle generation, deposition rate.
	Engineering	uniformity, selectivity and incorporation into the film were
	Manager	examined. This work resulted in a 30% increase in deposition
		rate. Similarly, ppb-ppm levels of impurities were introduced
	Carra	into HBr gas systems and accelerated lifetime tests were
	Core	conducted at three sites across the country. Measured by
	Technologist	quadrapole mass spectrometry gas composition in situ of Tungsten CVD and Al Etch process.
		• Responsible for gas, vacuum and chemical components
		evaluation, testing and supplier quality management. Managed an engineering group that tested and recommended gas, vacuum

	CVD Engineering Manager	 and chemical components for the CVD division, and developed process controls at suppliers. Supervised laboratory and trained individuals to develop specialized testing capabilities to characterize gas delivery and vacuum components. Also supported Etch, PVD and other divisions with common suppliers including vacuum pumps, vacuum transducers, flow controllers, valves and similar. Managed group of engineers and support personnel who developed gas panels and liquid source delivery systems for dielectric deposition. Delivered TEOS, TMP, TMB and many other organometallic precursors for SG, BPSG dielectric deposition. Developed organometallic CVD systems extensively. Designed multiple liquid source delivery systems for
	Systems Engineer	organometallic chemical precursors, i.e. bubblers, boilers, injectors
		 Managed CVD division design support group: CAD designers, drafters and CAD systems for division. Brought in first 3D CAD systems. Brought in first FEA program. Established and managed the customer engineering special group for the CVD division, which engineered all equipment modifications to meet customer specifications. These modifications included changes across the entire system, including process chambers, vacuum systems, gas delivery, power distribution, safety and robotics. Worked on the development and release of the landmark product, Precision 5000 CVD, one of which is now in the Smithsonian Institute. This was the first cluster tool for semiconductor manufacturing. Developed dielectric layers of silicon dioxide (glass or USG), boron phosphorous silicon glass (BPSG), phosphorous silicon glass (PSG), nitride, oxy-nitride, and others. Responsible for flow and vacuum equipment suppliers for company including MFC, valves, mechanical vacuum pumps, cryo-pumps, dry pumps, and others. Supported multiple divisions on these matters.
Doctora	I Dissertatio	on:
From: To:	1996 2002	Stanford University Stanford, California Ph.D. Completed a dissertation in the department of Materials Science &

Engineering leading to the Ph.D. degree.

Research includes:

• Plasma Deposition of Diamond-Like Carbon and Fluorinated Amorphous Carbon and the Resultant Properties and Structure

• Characterized stress, strain and hardness of films. Related the stress energy state to the diamond like nature of the thin films.

• Investigation of deposition mechanism fluorinated amorphous carbon (FLAC) and diamond-like carbon (DLC), low k dielectric materials.

• Modeled and conducted experiments on mechanism of ion energy, momentum and flux dependence for FLAC and DLC film synthesis in radio-frequency plasma discharges, including competing mechanisms of sub-plantation, ion-peening, sputtering, and etching.

• Constructed and instrumented a multi-purpose processing chamber for CVD, etch, and sputtering with measurement capability.

• Fabricated MIS capacitors to investigate the dielectric properties of fluorinated amorphous carbon (FLAC). Performed all wafer processing to construct MIS capacitors, including lithography, etch, CVD and PVD.

• Conducted thin film analysis including UV absorption spectroscopy, spectral ellipsometry, multi incident angle ellipsometry, Fourier transform infrared spectroscopy, profilometry, nano-indentation, and gravimetric measurements.

• Modeled dielectric properties and dispersion relationship of fluorinated amorphous carbon (FLAC), and compared spectral ellipsometric measurements to results of electrical CV tests and thickness measurements by profilometry using MIS structures.

Consulting History (Partial)

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From To	Sept. 2017 Jan 2018	UNICO Finite element analysis of new product concepts.
From To	July 2017 Dec 2017	Elwood National Forge Professional Engineering review of capital equipment. Finite element analysis.
From To	April 2017 May 2017	Jon Richards Co. (for Disneyland) Professional Engineering review of electric vehicle used as float at Disneyland.
From To	2017 Ongoing	Licensed Mechanical Engineering Professional Engineering letters and calculations for submission to building and environmental health departments. Miscellaneous clients.

From To:	2016 Ongoing	Confidential Client Reverse engineering of OLED display technology.
From To:	2016 2017	VWR Review of new semiconductor technologies for etching and particle reduction in semiconductor processing chambers.
From To:	2016 2017	TDA Research Finite element analysis of effluent treatment system for power plant carbon reduction treatments.
From To:	2016 Ongoing	Champion Telecom Engineering support, Finite element analysis, and design of "Cell Towers on Wheels" (COWs). Multiple projects. Analysis of trucks used to support emergency telecommunications.
From To:	2016 Ongoing	CarbonTech Pursue UL listing for thin film carbon heaters. Help productize the technology. Review codes for domestic use.
From To:	2015 2016	Phiston Engineering Review ability of equipment to destroy flash memory. Generate report to submit to NSA.
From To:	2015 2015 Duties	United States Air Force Concluded Advanced semiconductor process equipment engineering for Air Force Laboratory.
From	2013	United States Department of Justice, Antitrust Division
10:	Duties	Served as the industry expert for the DOJ in their investigation of the proposed merger between Applied Materials and Tokyo Electron.
From	m 2015 Ongoing Duties	VADA
10:		Fluid analysis of venting device.
From	n 2014 Completed	Chemithon
10.	Duties	Finite element analysis (FEA) and computational fluid dynamics (CFD) analysis of thermal and stress analysis of large industrial

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